

## CORPORATE PROFILE

CVD Equipment Corporation: NASDAQ: CVV  
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Date Founded: 1982  
Number of Employees: 192  
Updated as of: 12/31/2015

### COMPANY OVERVIEW

**Market Capitalization: \$62.5M**  
**Share Price: \$10.08 as of December 31st, 2015**  
**Shares Outstanding: 6,198,135**

CVD Equipment Corporation designs, develops, and manufactures a broad range of chemical vapor deposition, gas control, and other state-of-the-art equipment and process solutions used to develop and manufacture materials and coatings for research and industrial applications. This equipment is used by our customers to research, design, and manufacture these materials or coatings for aerospace engine components, medical implants, semiconductors, solar cells, smart glass, carbon nanotubes, nanowires, LEDs, MEMS, and other applications. Through our application laboratory, we provide process development support and process startup assistance with the focus on *enabling tomorrow's technologies™*.

### INVESTMENT HIGHLIGHTS

Chemical Vapor Deposition technology is used in many billion dollar growth markets to manufacture high performance materials. CVD applies its 33 years of IP expertise across numerous applications and industries to accelerate the commercialization of novel technologies and provide for increased production at lower cost.

CVD, through its FirstNano® R&D products, focuses on accelerating the commercialization of tomorrow's technologies. Working with innovators from universities, startups, and industrial companies, CVD helps them transition from R&D to production by providing a cost efficient road map for their pilot, production, and system solution needs. CVD also operates an application laboratory where novel ideas and pilot system performance can be quickly and economically evaluated.

CVD does not have to pick the winning companies, the winners pick us. Every system we sell opens up the opportunity for future multi-million dollar production equipment orders. As a result of being focused on chemical vapor deposition processes and selling our CVD research solutions worldwide, we have the diversified capability to solve many of the industrial applications presented to us, thus ensuring our future growth.